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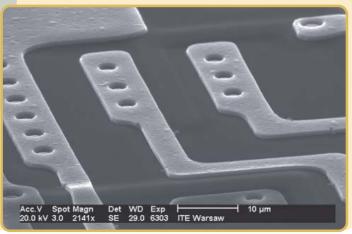
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Emulation of the ITE CMOS fabrication process (left) and SEM image of the structure (right)

Results obtained by Division of Silicon Microsystem and Nanostructure Technology, ITE, Warsaw, Poland

The process emulation approach at ITE uses 3D numerical simulation to produce highly accurate models of the effects of chemical reactions involved in fabrication.

More details on page 4.



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